



Evaporated Coating Particles Titanium Sputtering Target Ti90Nb10

Basic Information

- Place of Origin:
- Brand Name:
 - I Name:
- Certification:
- Model Number:
- Minimum Order Quantity: 2
- Price:
- Packaging Details:
- Delivery Time:
- Supply Ability:
- CDX-20220331H 20 piece Negotiable

ISO9001:2015 certification

plywood case

China

N/M

- 5-35 working days
- 50000KG/month



Product Specification

- Name:
- Key Words:
- Application:
- Density:
- Material:
- Highlight:
- Evaporated Coating Particles High Purity Metal Titanium Target Ti 5N 6N
- Titanium Sputtering Target
 - Liquid Crystal Display, Electronic Information
 - 4.75g/cm3
 - Titanium Niobium Alloy
- Evaporated Coating Alloy Target, Niobium Metal Sputtering Target, Ti90Nb10 Titanium Alloy Target



More Images



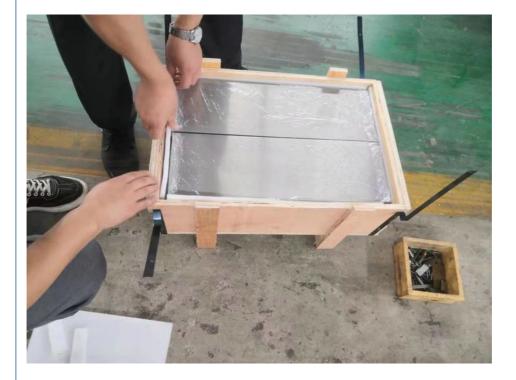


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Product Description

Titanium Niobium Alloy Target TiNb Target Ti90Nb10 Ti80 Nb20

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Usually we will provide a quality inspection report like this with the goods, which shows the chemical composition and physical properties

宝鸡丞德鑫钛金属材料有限公司

Baoji Quality Metals Co., Ltd 质量证明书

合同号. Contract No.	/ ^{ar} 品名称 Description	牌 号 Designatio No.		批号 Lot No/锭号 Heat No.			状态 Condition	规格 Size(mm)			数 量 Quantity	产品标准 Product Standard		
1	Titanium bar	GRI -		ÝTL20180126			м	16mm ×1000 mm		m	sample	ASTM B348		
室晶力学性能 Teasile test	试验温度 (℃) Test Temperature	抗拉强度 Rm(MPa) Tensile Strength		庫服强度 Rp _{8.1} (MPa) Yield Strength		A(斯后侍长来 A(%) Elongation		斯面收缩率 Z(%) Reduction of area		水压试验 Hydraulic pressure test	aulic Expand		用:扁试粥 Flattenin text
	Result	526		400		2	26		50		合格	路 合格		合格
具 宅	Bend Test		低信组织 Macrostructure		简倍组织 rostructur	外形 Dimer re Inspo	sional Visual			探伤者 Ultras Inspec	onie	nie /		
Others	1	1			1	合	合 格		合 格		ok		1	
				化	学成	份 Chemi	eal Compo	sition	(%)					
Result	n	AI	Su	1	1	1	1 1	e	C	N	н	0	Resid	ial element
	Remainder	1	1	1	1	3	/ 0.	11	0.06	0.03	0.001	0.07	$\leq 0, 10$	\$0.3
编制。 <u>兰宝云</u> Prepared by					載准。 Approx	開發紙 開始計 版量	全局清料 1 回加5 00 1 检验全	限公i Lin 定	Ta) D.		报告日期: Report Date	18年3月	15	

Titanium-niobium alloy sputtering targets are mainly used in the electronics and information industries, such as integrated circuits, information storage, liquid crystal displays, laser memories, electronic control devices, etc.; they can also be used in glass coating; they can also be used in wear-resistant materials, High temperature corrosion resistance, high-end decorative products and other industries.

1. Titanium and niobium target specifications: national standard or according to customer requirements and drawings.

2. Surface quality of titanium-niobium target: the surface is clean and smooth, free from peeling, folding, pores, cracks and other defects.

3. Titanium-niobium target packaging: Use woven bags, plastic foam, cardboard boxes, wooden boxes and other packaging that meet the transportation standards according to the specifications and dimensions of the goods to ensure safe transportation. Surface quality: The surface is clean and smooth, and there should be no defects such as cracks, folds, peeling, and pinholes. Reminder: Please clearly communicate with the customer service the detailed requirements of the baby's specifications, material grades, and use environment when purchasing the baby to avoid unnecessary trouble. Commonly used sizes are in millimeters (mm) by default.

Our company is a high-tech company that produces titanium sputtering targets, evaporation coating materials, high-purity metal materials, titanium alloy bulk materials, advanced ceramic functional materials and application technology research and development.

The titanium materials we provide have been widely used in aerospace, optical glass, new energy, military technology, liquid crystal display, electronic information, data storage, magnetic recording, metallurgy, biomedicine, and other industries.

